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Perpendicular magnetic anisotropy of Mn4N films on MgO(001) and SrTiO3(001) substrates
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Perpendicular magnetic anisotropy of Mn$_4$N films on MgO(001) and SrTiO$_3$(001) substrates

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We grew Mn$_4$N epitaxial thin films capped with Au layers on MgO(001) and SrTiO$_3$(001) substrates by molecular beam epitaxy. Perpendicular magnetic anisotropy (PMA) was confirmed in all the samples at room temperature from the magnetization versus magnetic field curves using superconducting quantum interference device magnetometer. From the $\omega$-2$\theta$ x-ray diffraction (XRD) and $\phi$-2$\theta$ XRD patterns, the ratios of perpendicular lattice constant $c$ to in-plane lattice constant $a$, $c/a$, were found to be about 0.99 for all the samples. These results imply that PMA is attributed to the in-plane tensile strain in the Mn$_4$N films.

In recent years, new functional spintronics devices such as spin-transfer torque random access memory and current-driven domain wall motion nonvolatile memory have been proposed. In such devices, materials that give high spin polarization in electron transport need to be sought. Therefore, highly spin polarized materials have attracted much attention from both the theoretical and experimental points of view. We have done a lot of research on inverse perovskite ferromagnetic nitrides (Co,Fe)$_4$N. This material is theoretically predicted to have negative but large spin polarization. So far, we succeeded in epitaxial growth of Fe$_4$N, Co$_4$N, and (Co,Fe)$_4$N thin films on SrTiO$_3$(STO)(001) substrates by molecular beam epitaxy (MBE) and evaluated the spin and orbital magnetic moments per Co and Fe atoms by x-ray magnetic circular dichroism and other basic properties such as spin-resolved valence band structure and negative anisotropic magneto resistance effect. Among ferromagnetic nitrides, there have been a very limited number of reports about perpendicular magnetic anisotropy (PMA) in Mn$_4$N films thus far. PMA has attracted increasing interest, because it is useful for spintronics devices like low current-induced magnetization switching magnetic tunnel junction devices and others. A lot of studies have been done on Co$_2$FeAl, CoFeB, and CoFe$_2$O$_4$ films. PMMA is considered to be caused by the magnetoelastic coupling due to the in-plane tensile strain in the CoFe$_2$O$_4$ thin films. PMA was observed in the Mn$_4$N films on Si(001) by reactive sputtering, and those on SiC(0001) by MBE. However, they did not measure the lattice constants in the films. Thus, the origin of PMA was not fully understood. Recently, Tsunoda and Kabara prepared a 50-nm-thick Mn$_4$N film on MgO by reactive sputtering. They attributed the observed PMA to have negative but large spin polarization. So far, we succeeded in epitaxial growth of Fe$_4$N, Co$_4$N, and (Co,Fe)$_4$N thin films epitaxially on MgO(001) and SrTiO$_3$(001) substrates by MBE, and investigated the influence of lattice mismatch on the magnitude of in-plane strain and PMA in the films. The lattice mismatches for Mn$_4$N(001)/MgO(001) and Mn$_4$N(001)/STO(001) are $\pm 8\%$ and $\pm 1\%$, respectively.

We grew Mn$_4$N thin films on MgO(001) and STO(001) substrates using a solid source Mn and radio-frequency N$_2$ plasma at a substrate temperature of 450°C. After the growth, the films were in-situ covered with Au at room temperature (RT) in the same MBE chamber to prevent oxidation of the surfaces. Samples were prepared as summarized in Table I. The crystal quality of grown layers was evaluated by reflection high-energy electron diffraction (RHEED), $\omega$-2$\theta$ Cu–K$_x$ x-ray diffraction (XRD) and $\phi$-2$\theta$ XRD. Ge(220) single crystals were used to make x-rays monochromatic. Au/Mn$_4$N layer thicknesses were evaluated using a conventional surface profiler. The magnetization versus magnetic field ($M$–$H$) curve was measured at RT using the superconducting quantum interference device (SQUID) magnetometer. The external magnetic field ($H$) of $\pm 5$–5 T was applied in the normal and in-plane directions of samples.

Streaky RHEED patterns were obtained for all the samples. Figures 1(a)–1(d) show the out-of-plane $\omega$-2$\theta$ XRD patterns of samples A–D, respectively. The diffraction peaks of Mn$_4$N(002) and (004) were observed in all the samples. Figures 2(a)–2(d) show the in-plane $\phi$-2$\theta$ XRD patterns of samples A–D, respectively. The scattering vector was set along the MgO[100] and STO[100] directions. Similarly, the diffraction peaks of Mn$_4$N(200) and (400) were observed in all the samples. These results mean that the Mn$_4$N thin films were epitaxially grown on MgO(001) and STO(001) substrates. From the results of XRD measurements, we calculated the $c/a$ ratios in samples A–D as summarized in Table I. The $c/a$ ratios were calculated to be 0.991, 0.990, 0.995, and 0.989, respectively. These results show that there is an in-plane tensile strain existed in all the Mn$_4$N films. It is very important to notice here that the $c/a$ ratios were almost the same in samples A–D, in spite of the different substrates and different Mn$_4$N layer thicknesses. Thus, we speculate that the in-plane tensile strain was not caused by the lattice. 

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mismatch but by other factors, for example, difference in thermal expansion coefficient between substrate and Mn$_4$N. The $c/a$ ratio of 0.99 was also observed even in the 50-nm-thick Mn$_4$N film. Another possibility is that 12 nm in sample A was already too thick to make the Mn$_4$N films pseudomorphic.

Figures 3(a)–3(d) show the $M$-$H$ curves of samples A–D, respectively, measured by SQUID magnetometer at RT. We deduced the diamagnetic component of the substrates from the slope of raw $M$-$H$ curves at large $H$ region, and subtracted it from the raw data. The magnetization of the films was saturated at such large $H$ regions. We see that the hysteresis curves were clearly open in all the samples when $H$ was applied perpendicular to the films. On the other hand, the hysteresis curves were closed when $H$ was applied in the in-plane direction. These results show that PMA surely appeared in the Mn$_4$N films. The saturation magnetization ($M_S$) value was approximately 145 emu/cc in samples A–D. This value is larger than that reported (110 emu/cc) in the Mn$_4$N film on MgO(001) at 300 K. The coercive field and anisotropic magnetic field ($H_K$) were approximately 2.5k and 30 kOe, respectively. The total uniaxial magnetic anisotropy energy ($E_A = M_S H_K/2$) was deduced to be approximately 2.2 Mergs/cc for samples A–D. This value is twice as large as that reported in the Mn$_4$N film on MgO(001) substrates by reactive sputtering ($E_A \sim 1.0$ Mergs/cc).

$E_A$ in the perpendicular magnetization film is given by (Refs. 22 and 23)

$$E_A = K^V + \frac{K^I}{t} - 2\pi M_S^2,$$

(1)

where $K^V$ is the volume anisotropy energy, $K^I$ the interfacial anisotropy energy, $t$ the ferromagnetic film thickness, and $-2\pi M_S^2$ the shape anisotropy energy. As for the presence of the interfacial PMA, there have been no reports in Mn$_4$N/MgO and Mn$_4$N/STO. We think that the contribution of $K^I/t$ term to PMA is small, if any, because the Mn$_4$N layer thickness $t$ was thicker than 12 nm in samples A–D. In the case of Co$_2$FeAl/MgO and CoFeB/MgO, interfacial PMA was confirmed only in very thin films (~1 nm). On the other hand, PMA was observed even in much thicker Mn$_4$N films (50 nm). This means that PMA was observed even when the $K^I/t$ term was small in the Mn$_4$N film, implying that the interfacial energy plays a minor role in the appearance of PMA. Thus, we suppose that PMA was induced in the Mn$_4$N films, that is $E_A > 0$, because of $K^V > 2\pi M_S^2$. When the $c$-axis-oriented cubic thin film receives tensile strain in the in-plane direction, it becomes tetragonal. The uniaxial magnetic anisotropy energy induced by magnetostatic coupling ($K_U^V$) is given by (Ref. 24)

$$K_U^V = -\frac{3}{2} \frac{2}{\lambda_{100}} (C_{11} - C_{12}) \left(\frac{a-c}{a_0}\right),$$

(2)

TABLE I. Sample preparation: substrate, Mn$_4$N layer thicknesses, Au layer thickness, and $c/a$ ratios are shown.

<table>
<thead>
<tr>
<th>Sample</th>
<th>Substrate</th>
<th>Mn$_4$N (nm)</th>
<th>Au (nm)</th>
<th>$c/a$ ratio</th>
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<tr>
<td>A</td>
<td>MgO(001)</td>
<td>12</td>
<td>4</td>
<td>0.991</td>
</tr>
<tr>
<td>B</td>
<td>STO(001)</td>
<td>12</td>
<td>4</td>
<td>0.990</td>
</tr>
<tr>
<td>C</td>
<td>MgO(001)</td>
<td>26</td>
<td>5</td>
<td>0.995</td>
</tr>
<tr>
<td>D</td>
<td>STO(001)</td>
<td>28</td>
<td>5</td>
<td>0.989</td>
</tr>
</tbody>
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FIG. 1. Out-of-plane $\phi$-20 XRD patterns for (a) sample A, (b) sample B, (c) sample C, and (d) sample D.

FIG. 2. In-plane $\phi$-20 XRD patterns of (a) sample A, (b) sample B, (c) sample C, and (d) sample D.
where $\lambda_{100}$ is the magnetostriction constant along the [100] orientation of the magnetic thin film. $C_{11}$ and $C_{12}$ the elastic moduli in the directions perpendicular and parallel to the surface, respectively, $a_0$ the bulk lattice constant. $\lambda_{100}$ is negative in Mn$_4$N$^{17,18}$ It is reasonable to think that $C_{11}$ is greater than $C_{12}$ in most of cubic metals and therefore in inverse perovskite nitrides$^{27,28}$ The presence of in-plane tensile strain ($c < a$) thus gives rise to $K_V > 0$ in samples A–D. We therefore conclude that positive $K_V$ and small $2\pi M_s^2$ caused PMA in the Mn$_4$N films. This mechanism of PMA is similar to that in CoFe$_2$O$_4$ films$^{24,25}$ The value of $-2\pi M_s^2$ was $-0.13$ Mergs/cc in samples A–D, which means that the $K_V$ value is $2.3$ Mergs/cc because $E_A$ is $2.2$ Mergs/cc. About the magnetcocrystalline anisotropy, the easy magnetization axis of bulk Mn$_4$N is along the ⟨111⟩ axes$^{29}$ However, there have been no reports on the magnetcocrystalline anisotropy energy in both cubic and pseudo-morphic Mn$_4$N. We measured the in-plane $M$-$H$ curves along the [100] and [110] axes of Mn$_4$N films on STO. However, significant difference was not observed in the hysteresis curves. This means that contribution of magnetcocrystalline anisotropy to the PMA can be considered to be small. Similar discussions were made in Ref. 30. Magnetic torque measurements help us distinguish the contribution of magnetcocrystalline anisotropy from the others in Mn$_4$N films$^{31}$ It is true that dependence of PMA on c/a ratio enables us to clarify the origin of PMA much more strongly. But the fact that all the Mn$_4$N films with c/a < 1 showed clear PMA implies that the observed PMA was caused by the in-plane tensile stress in the Mn$_4$N.

In summary, we grew Mn$_4$N epitaxial thin films of different layer thicknesses on two kinds of substrates, MgO(001) and STO(001), by MBE. PMA was clearly observed in the $M$-$H$ curves for all the samples at RT. The c/a ratios in the Mn$_4$N films were found to be approximately 0.99 from the XRD measurements for all the samples regardless of the different substrates and the different layer thicknesses. We therefore attributed the observed PMA to the in-plane tensile stress in the Mn$_4$N films.

The authors thank Dr. M. Tsunoda of Tohoku University for useful discussion. $M$-$H$ curves measurements were performed with the cooperation of Dr. R. Akiyama, Dr. K. Suzuki, Dr. H. Yanagihara, Dr. T. Koyano, Professor S. Kuroda, and Professor E. Kita of University of Tsukuba.

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**FIG. 3.** $M$-$H$ curves of (a) sample A, (b) sample B, (c) sample C, and (d) sample D, measured at RT. $H$ was applied normal and parallel to the samples.